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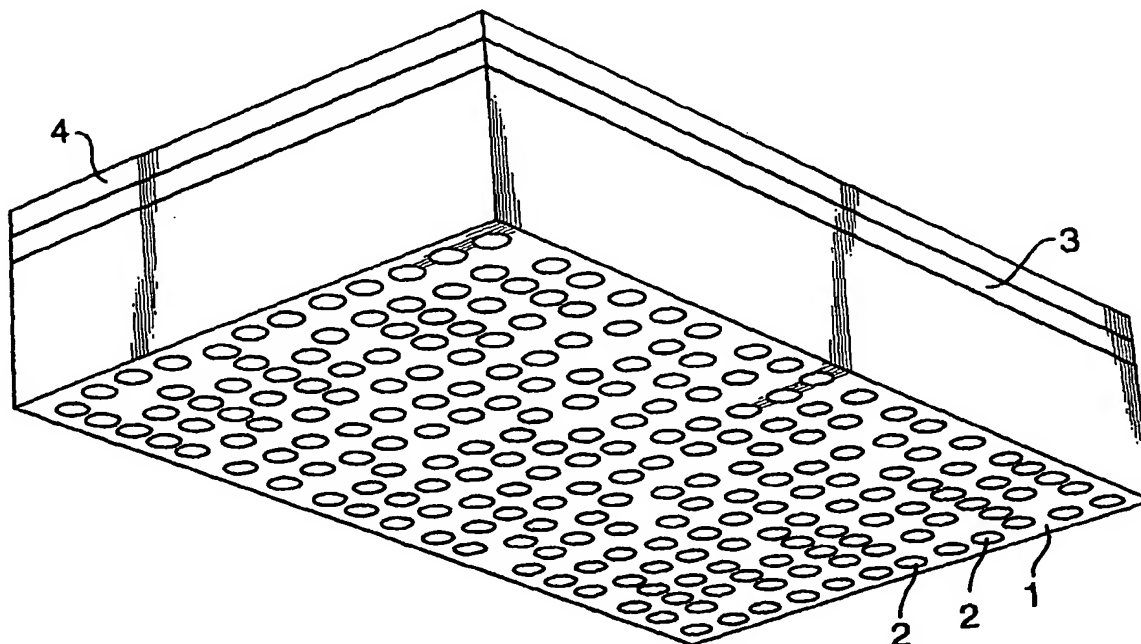
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(54) Title: METHOD FOR THE MANUFACTURE OF A DISPLAY



(57) Abstract: A method for the manufacture of displays, in particular flexible displays, is disclosed. A substrate (1) provided with small openings (2), rendering the substrate porous and forming trenches in the substrate (1), is used. A removable layer (3) is attached to the substrate (1). An etch and temperature resistant layer (4) is deposited onto the removable layer (3), and a display is processed on said etch and temperature resistant layer (4). The removable layer (3) is removed by etching through the openings (2) in the substrate (1) and the substrate may be re-used.